This article was downloaded by:

On: 29 January 2011

Access details: Access Details: Free Access

Publisher Taylor & Francis

Informa Ltd Registered in England and Wales Registered Number: 1072954 Registered office: Mortimer House, 37-41 Mortimer Street, London W1T 3JH, UK



Phosphorus, Sulfur, and Silicon and the Related Elements

Publication details, including instructions for authors and subscription information: http://www.informaworld.com/smpp/title~content=t713618290

STRUCTURAL ORIGIN OF GLASS FORMATION IN GROUP IV DISELENIDES

P. Boolchand^a; J. Hernandez^b

^a Department of Electrical and Computer Engineering and Department of Physics, University of Cincinnati, Cincinnati, Ohio ^b Energy Conversion Devices Troy, Michigan

To cite this Article Boolchand, P. and Hernandez, J.(1988) 'STRUCTURAL ORIGIN OF GLASS FORMATION IN GROUP IV DISELENIDES', Phosphorus, Sulfur, and Silicon and the Related Elements, 38: 3, 305 — 316

To link to this Article: DOI: 10.1080/03086648808079726 URL: http://dx.doi.org/10.1080/03086648808079726

PLEASE SCROLL DOWN FOR ARTICLE

Full terms and conditions of use: http://www.informaworld.com/terms-and-conditions-of-access.pdf

This article may be used for research, teaching and private study purposes. Any substantial or systematic reproduction, re-distribution, re-selling, loan or sub-licensing, systematic supply or distribution in any form to anyone is expressly forbidden.

The publisher does not give any warranty express or implied or make any representation that the contents will be complete or accurate or up to date. The accuracy of any instructions, formulae and drug doses should be independently verified with primary sources. The publisher shall not be liable for any loss, actions, claims, proceedings, demand or costs or damages whatsoever or howsoever caused arising directly or indirectly in connection with or arising out of the use of this material.

STRUCTURAL ORIGIN OF GLASS FORMATION IN GROUP IV DISELENIDES

P. BOOLCHAND

Department of Electrical and Computer Engineering and Department of Physics
University of Cincinnati, Cincinnati, Ohio 45221-0030

and

J. HERNANDEZ Energy Conversion Devices Troy, Michigan 48084

Abstract SiSe₂, GeSe₂ and SnSe₂ crystallize in a quasi 1-d, quasi 2-d and a quasi 2-d structure with the cations possessing a coordination number (CN) of 4,4 and 6, respectively. SiSe₂ and GeSe₂ melts readily yield bulk glasses upon water quenching, while non-crystalline SnSe₂ can only be prepared by vapor deposition onto room temperature substrates as amorphous thin-films. In the non-crystalline state, a cation CN of 4 is preferred largely because tetrahedral Si(Se_{1/2})₄, Ge(Se_{1/2})₄ and Sn(Se_{1/2})₄ units form the principal building blocks of these networks. Furthermore, tetrahedra share predominantly edges in SiSe₂ glass, a combination of both corners and edges in GeSe₂ glass and corners in amorphous SnSe₂ films. The intermediate range order of these non-crystalline materials has emerged from Raman scattering, Mossbauer spectroscopy and neutron structure-factor measurements.

INTRODUCTION

Most inorganic solids can be made amorphous by vapor deposition onto suitably cooled substrates. However only a select few inorganic melts can be readily supercooled by an air or water quench to yield bulk glasses which solidify at the glass transition temperature. The chalcogenides and oxides of the group IV and V elements represent some of the best-known glass-formers found in nature.

There are growing indications that the origin of glass formation may in general be the consequence of a delicate balance between chemical and mechanical stability of glassy networks¹. In particular for the binary chalcogenides of the group IV and V elements, the glass forming tendency (GFT) is promoted when anions and cations conform to the 8-N coordination rule of bonding in corresponding crystals. Satisfaction of the 8-N rule in crystals is thought to promote covalently bonded networks in corresponding glasses, and this represents the chemical stability factor. The lone-pair

chemistry of chalcogens promotes in general a low average CN \simeq 2.4 in such molecular crystals which possess either a chain-like (quasi 1-d) or layer-like (quasi 2-d) morphology. J.C. Phillips and M.F. Thorpe recently recognized² that in covalently bonded networks when <CN> \simeq 2.4, such networks are optimally constrained in a mechanical sense. The threshold <CN>=2.4 leads to mechanical stability of glassy networks. These considerations permit one to understand why in the As_X(S or Se)_{1-X} binary the mechanical and chemical stability is optimized at x=2/5 leading to an exceptional GFT at this composition even though there exists a crystalline compound of exactly the same stoichiometry.

The origin of GFT has been a subject of several discussions for the past fifty years. Broadly speaking two opposed explanations have attracted wide support: the microcrystalline model based on crystal-like large molecular clusters and a stochastic model based on a random network or random-packing model. Recent experimental evidence³ in a variety of chalcogenide glasses appears to support models based on molecular clusters. In the present work we shall review some of this evidence particularly for group IV diselenides.

CRYSTAL STRUCTURES OF SiSe₂, GeSe₂ and SnSe₂ and GLASS FORMING TENDENCY

The correlation between crystal morphology and GFT as a function of cation mass in the group IV diselenides provides an interesting trend. Table 1 and Figure 1 lists some of the relevant data.

SiSe2

The ambient pressure polymorph of crystalline SiSe₂ possesses a quasi 1-d molecular structure⁴ consisting of infinitely long chains of edge-sharing (ES) Si(Se_{1/2})₄ tetrahedra (fig. 1a). In this structure, adjacent chains have their Si-Se₂-Si planes at right angles to each other leading to an out of phase stacking of chains. Peter and Krebs⁴ have noted that in this structure the intrachain and interchain non-bonding Se-Se contacts are characterized by nearly the same length. SiSe₂ melts at 970°C into a rather viscous liquid which readily yields a bulk glass upon water quenching.

<u>β-GeSe</u>2

The high-temperature polymorph of $(\beta$ -) GeSe₂ consists of a layered structure⁵. In a given layer both corner-sharing (CS) and ES tetrahedra occur in

Group IV diselenide	<cn></cn>	Molecular Structure and Morphology	Glass Forming Tendency
SiSe ₂	2.66	chains of ES tetrahedra;	high; T _g =460°C T _X =600°C; T _m =970°C
β-GeSe ₂	2.66	layers of CS and ES tetrahedra; 2-d	high; T _g =425°C T _x =480°C; T _m =735°C
SnSe ₂	4.0	layers of octahedral Sn(Se _{1/3}) ₆ units; 2-d	poor T _x ≈200°C; T _m =675°

Table I. Glass (T_g) , Crystallization (T_x) , and Melting (T_m) Temperature of Indicated Materials

the ratio 2:1. One may visualize the layers (Fig. 1b) to consist of chains of CS tetrahedra which are laterally cross-linked by a pair of ES tetrahedra, with the arrangement looking much like a step-ladder. The inter-layer separation is determined by the non-bonding Se-Se contacts mediated by Van der Waal's forces. The GFT in binary Ge_XSe_{1-x} melts has been extensively studied and reveals that bulk glasses are readily formed by water quenching over a wide Ge concentration 0<x<0.43 including the stoichiometric composition x=1/3, at which the glass transition temperature $T_g(x)$ exhibits a local maximum⁶. SnSe₂

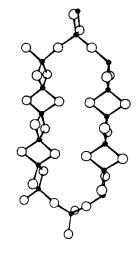
SnSe₂ is an indirect band gap semiconductor and possesses a close-packed layered structure⁷ based on CdI₂. In this structure cations and anions possess a CN=6 and 3 as shown in Figure 1c. SnSe₂ melts at 675°C and attempts to supercool such melts by a water quench have invariably produced the crystal rather than a glass. However, we have succeeded⁸ in preparing amorphous thinfilms of SnSe₂ by RF diode sputtering onto Al substrates held near room temperature. Molecular structure of such films has been probed⁸ in optical absorption edge, Raman scattering and Mossbauer spectroscopy experiments. Results of some of these experiments will be discussed in the next section.

MOLECULAR STRUCTURE OF GROUP IV DISELENIDES SiSe2

Gladden and Elliot⁹ have recently generated computer models of SiSe₂ glass to explain the structure factor recorded by R.W. Johnson¹⁰ et al. in inelastic neutron scattering experiments. The algorithm for computer generating

FIGURE 1a taken from ref. 9 shows a fragment of ES Si(Se_{1/2})₄ units in the crystal (left) and fragment of cross-linked chain cluster (right). The filled circles represent Si atoms.

(a)



(b)

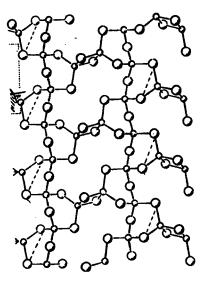
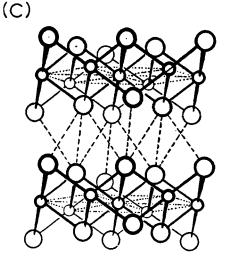


FIGURE 1b shows a layer of β -GeSe₂. It consists of chains of CS (GeSe_{1/2})4 units crosslinked by a pair of ES units. In the glass the edges of this fragment are reconstructed to have Se-Se dimers as shown by the broken lines.

FIGURE 1c shows closed-packed structure of SnSe₂ in which Sn (small atom) possesses a CN=6 while Se (large atom) a CN=3.



specific models of SiSe₂ glass consisted of starting from various seeds such as random chain seeds, locally parallel seeds and microcyrstalline seeds. A 1200 atom assembly packed at the observed glass density was generated. The structure factor of various computer generated models was compared to the neutron structure factor. This analysis clearly reveals that a purely continuous random network or a purely microcrystallite based model is inappropriate to describe the structure of SiSe₂ glass. On the other hand molecular fragments based on ES chains of Si(Se_{1/2})₄ tetrahedra some of which are present in a configuration as found in the crystal and others as found in a cross-linked chain cluster¹¹ (CLCC) can account for the principal features of the neutron structure factor rather well.

Historically, Raman scattering experiments of Tenhover et al.¹² and independently Griffiths et al.¹¹ were one of the first to probe the molecular structure of SiSe₂ glass. Upon contrasting the glass and crystal vibrational modes in the bond-stretching regime (figure 2), it becomes clear that the sharp modes at 245cm⁻¹ and 205cm⁻¹ observed in the crystal spectrum have analogues in the glass spectrum, while modes at 234cm⁻¹ and 218cm⁻¹ in the glass have no counterparts in the crystal. These results led Griffiths et al.¹¹ to propose a CLCC model of SiSe₂ glass in which the 234cm⁻¹ and 218cm⁻¹ modes are identified with CS tetrahedra that cross-link ES tetrahedral chains.

Recently Enzweiler et al. 13 have performed Mossbauer spectroscopy experiments on SiSe₂ using both 125Te and 129Tem as a tracer. In these experiments one probes the anion site chemistry by replacing available Se sites of the network by isovalent Te atoms. The results show that although one type of a Te site is populated in the crystal, two types of Te sites occur in the glass. Comparison of the nuclear hyperfine structure of the majority site in the glass and the crystal site lead to the conclusion that in the glass network, Te dopant prefers replacing Se bridging sites at the more flexible CS tetrahedra in contrast to replacing the more constrained Se bridging sites of ES tetrahedra in the crystal. The picture emerging from all these results appears to be one where the glass network predominantly consists of ES tetrahedral chains which are crosslinked by CS tetrahedra. The latter may be viewed as topological defects of the glass network.

GeSe₂

Two recent articles on the molecular structure of GeSe2 glass have

appeared somewhat coincidently in the same book. One of these by Lucovsky¹⁴ emphasizes the stochastic model based largely on a continuous random network of Ge(Se_{1/2})₄ tetrahedra. The discussion is largely based on an improved Bethe-Lattice formalism to rationalize the observed Raman vibrational modes. The other article by Boolchand¹⁵ discusses new Mossbauer and Raman scattering results on pseudobinary glasses where the role of composition on the evolution of bond and site distributions is systematically analysed. The latter experimental results decisively favor a model of GeSe₂ glass based on the principle of broken chemical order.

Specifically the glass network is pictured as composed of two types (A,B) of molecular clusters: a layer-like large molecular cluster (A) based on β -GeSe₂ whose edges are dressed by Se-dimers and a compensating Ge-rich chain-like molecular cluster (B) composed of ethane-like Ge₂Se₆ units. The A and B clusters are easily discriminated in ¹¹⁹Sn Mossbauer spectroscopy largely because of two reasons. First the isovalent Sn atom as a dilute impurity in the glass replaces available Ge sites in the network randomly. Second the local symmetry of cations in the A-cluster is tetrahedral, but becomes trigonal in the B-cluster and this leads to widely different nuclear hyperfine structures for the two sites. Figure 3 depicts the compositional variation of the different molecular clusters (A, B and C) in binary Ge_xSe_{1-x} and Ge_xS_{1-x} glasses deduced from deconvoluting 119Sn Mossbauer spectra of the glasses. The Ccluster is thought to represent a fragment of a distorted rocksalt phase based on the layered structure of c-GeS and c-GeSe as discussed elsewhere 16. This phase diagram also provides a convenient basis to understand not only the compositional variation of Raman vibrational mode strengths in binary (Ge-S and Ge-Se) and ternary (Ge-Sn-Se₂) glasses, but also the photo- induced reversible reconstruction of GeSe2 glass network documented by Griffiths et al. 17 and the cryobaric Raman measurements on GeS2 of Weinstein et al. 18 The so called A₁ companion-line observed at 215cm⁻¹ is identified as a cluster-edge mode of CS tetrahedra associated with broken chemical order as substantiated by Murase¹⁹ and Stevens²¹ but not as a mode of chemically ordered ES tetrahedra as suggested by Sugai¹⁹.

An important aspect of the Figure 3 phase diagram¹⁶ is the degree of broken chemical order $I_B/I \simeq 0.16(1)$ for GeSe₂ glass which leads to an A

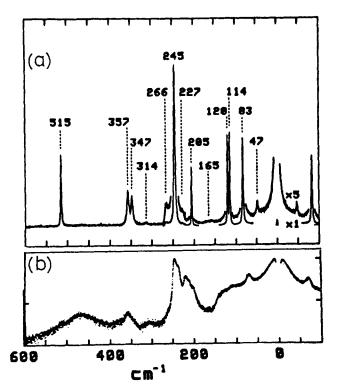
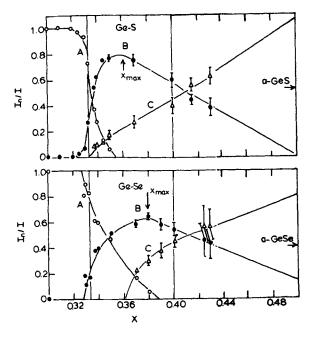


FIGURE 2. Raman scattering in crystalline (a) and glassy (b) SiSe₂ taken from ref. 11 shows bondstretching modes at 245cm⁻¹ and 205cm⁻¹ in the crystal but modes at 245cm⁻¹, 218cm⁻¹, and 205cm⁻¹ in the glass.

FIGURE 3. Molecular Phase Diagram of binary Ge_XS_{1-X} (top) Ge_XSe_{1-X} (bottom) glasses as a function of Ge concentration x showing presence of A, B and C molecular clusters. This figure is taken from ref. 16.



cluster size dimension of 50 to 75Å in lateral width. Remarkably, ¹²⁹I Mossbauer emission spectroscopy²⁰ experiments quantitatively lead to the same degree of broken anion site chemical order in GeSe₂ glass. In the latter experiments analysis of the results is compounded by the fact that Te site selectivity for the Se-edge versus Se-interior sites in the A cluster has to be included¹⁵. The B-molecular phase is unstable in corresponding crystals. Its presence in the stoichiometric glass acts to promote GFT by suppressing crystallization.

SnSe₂

RF sputtered amorphous thin-films of SnSe₂ crystallize near $T_x \simeq 200^{\circ}$ C which can be tracked in ¹¹⁹Sn Mossbauer spectroscopy and Raman scattering experiments as shown in figure 4 and 5. In the Mossbauer spectra (figure 4) the isomer-shift of the main absorption at $\delta = 1.56$ mm/s suddenly shifts to $\delta = 1.35$ mm/s upon crystallization. We identify this result with a change in Sn CN from 4 in the amorphous film to 6 in the crystalline state. The shift $\delta = 1.56$ mm/s is characteristic of Sn as an impurity in g-GeSe₂ or g-Ge_{1-x}Sn_xSe₂ alloys²¹, and it is identified with a Sn atom present in a tetrahedral Sn(Se_{1/2})4 unit. In Raman scattering the strong (polarized) band at 182.5cm⁻¹ in the amorphous film represents an A_1 symmetric stretch of Sn(Se_{1/2})4 units. This identification is inferred from our previous work²¹ on g-Ge_{1-x}Sn_xSe₂ alloys, where the A_1 mode of GeSe₂ glass (x=0) at 202cm⁻¹ progressively red-shifts as a function of SnSe₂ alloying. The 182.5cm⁻¹ band is replaced by a sharp and narrow mode at 186cm⁻¹ characteristic of hexagonal SnSe₂ when the film crystallizes.

It becomes apparent from these spectroscopic results that amorphous $SnSe_2$ films largely consist of a tetrahedral network of $Sn(Se_{1/2})_4$ units. In g- $Ge_{1-x}Sn_xSe_2$ alloys, we had previously noted²¹ that an abrupt red-shift of A_1 mode frequency occurs near $x\approx0.25$. This shift was interpreted as a network dimensionality change from 2-d like $(x_{\sim}0.25)$ to 3-d like $(x_{\sim}0.25)$. This transition appears as a precursor to the realization of a fully chemically ordered 3-d Zachariasen network²¹ at $x\approx0.35$. On this basis, we speculate that the network structure of a-SnSe₂ films probably consists of CS $Sn(Se_{1/2})_4$ tetrahedra.

Some degree of broken chemical order into Se-rich and Sn-rich regions appears to be an intrinsic feature of the as deposited amorphous SnSe₂ films. The Sn-rich phase probably consists of a microcrystalline SnSe phase and it

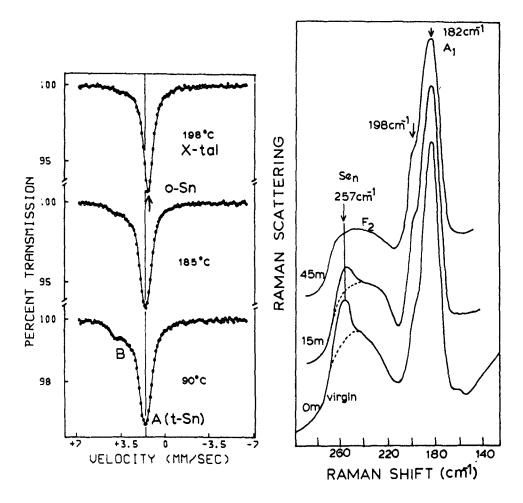


FIGURE 4. ¹¹⁹Sn spectra of a-SnSe₂ films exhibit a tetrahedral (A) site and a non-tetrahedral (B) site. Crystallization leads to octahedral (o) Sn as in c-SnSe₂.

FIGURE 5. Room temperature Raman scattering from a-SnSe₂ films cycled through 180°C show extinction of the 257cm⁻¹ band with indicated annealing time.

gives rise to a doublet feature having a large positive isomer-shift in the Mossbauer spectra (Figure 4). The presence of the compensating Se-rich phase in the films gives rise to additional Raman scattering at 257cm⁻¹ which is usually attributed to a Se-Se stretch in either. Sub-T_x thermal annealing promotes chemical ordering in the films as the Sn-rich and Se-rich phase reconstruct. This becomes clear from an increase in the tetrahedral fraction of

the amorphous films upon thermal annealing and a concommitant drop in Raman scattering strength near 257cm^{-1} (Figure 1). Nevertheless a measurable degree of broken chemical order (~10%) persists in the annealed state and appears to act as a barrier against crystallization of the films at $T < T_x$.

CONCLUDING REMARKS

The molecular conformations present in c-SiSe₂ and β -GeSe₂ and corresponding melt-quenched glasses bear a close relationship to each other and these can be regarded as flexible and low-pressure polymorphs. These molecular clusters are chemically stable and almost optimally constrained and therefore promote glass formation. Hexagonal SnSe2 and amorphous SnSe2 on the other hand, provide examples of two widely different molecular conformations, the former a high-pressure one while the latter a low-pressure one. The high pressure conformation is mechanically rigid and it is the reason why SnSe2 melts are poor glass formers. In the non-crystalline state the tetrahedral networks exhibit a systematic trend consisting predominantly of ES units in a quasi 1-d morphology for SiSe2, a combination of ES and CS units in a quasi 2-d morphology for GeSe2 and primarily of CS units in a quasi 3-d morphology for SnSe2, respectively. The topological defects metastabilizing respective networks appear to be CS tetrahedra in g-SiSe2, homopolar bonds leading to molecular phase separation in g-GeSe2, and Sn-rich and Se-rich nanoclusters dressing the tetrahedral network in a-SnSe2.

ACKNOWLEDGEMENTS

The work on amorphous SnSe₂ films was done in collaboration with Napoleon Fermigoni, Dr. John deNeufville and Stan Ovshinsky, to whom all I am indebted for their support. Mark Stevens assisted in the Mossbauer spectroscopy experiments. This work was supported by the National Science Foundation grant DMR-85-21005.

REFERENCES

J.C. Phillips in <u>Dynamical Aspects of Structural Changes in Liquids and Glasses</u>, edited by C.A. Angell and M. Goldstein in Annals of N.Y. Academy of Science <u>484</u>, 271 (1986).

- M.F. Thorpe, J. Non Cryst. Solids <u>57</u>, 355 (1983); J.C. Phillips J. Non Cryst. Solids <u>34</u>, 153 (1979); <u>43</u>, 37 (1981).
- 3. D. Ruffolo and P. Boolchand Phys. Rev. Lett. <u>55</u>, 242 (1985).
- 4. J. Peters and B. Krebs, Acta Cryst. B38, 1270 (1982).
- 5. G. Dittmar and H. Schafer Acta Cryst. B31, 2060 (1975).
- D.J. Sarrach, J.P. deNeufville and W.L. Hayworth J. Non Cryst. Solids <u>22</u>, 245 (1976).
- G. Busch, C. Fröhlich, F. Hullinger, E. Steigmeier, Helv. Phys. Acta <u>34</u>, 359 (1961).
- 8. P. Boolchand, M. Stevens, N. Fermigoni, J. Hernandez, J.P. deNeufville (unpublished).
- 9. L.F. Gladden and S.R. Elliott (private communication).
- 10. R.W. Johnson et al., J. Non Cryst. Solids 88, 366 (1986).
- J.E. Griffiths, M. Malyj, G.P. Espinosa and J.P. Remeika Phys. Rev. <u>B30</u>, 6978 (1984).
- 12. M. Tenhover, M.A. Hazle and R.K. Grasselli Phys. Rev. Lett. 51, 404 (1983).
- R.N. Enzweiler, P. Boolchand and J.E. Griffiths in Proceedings of the 2nd International Conference on the <u>Effects of the Modes of Formation on the Structure of Glasses</u>, edited by R.A. Weeks and D.L. Kinser, Nashville, TN June 15-18, 1987 (to be published).
- G. Lucovsky in <u>Physical Properties of Amorphous Materials</u>, edited by David Adler, Brian B. Schwartz, Martin C. Steele, (Plenum, New York, 1985) pp. 277-310.
- 15. P. Boolchand ibid pp. 221-257.
- P. Boolchand, J. Grothaus and J.C. Phillips, Solid State Comm. 45, 183 (1983) also see P. Boolchand in Comments Cond. Mat. Physics 12, 163 (1986).
- 17. J.E. Griffiths, G.P. Espinosa, J.P. Remeika and J.C. Phillips Phys. Rev. B25, 1271 (1982).
- B.A. Weinstein, and M.L. Slade in A.I.P. Conference Proceedings <u>120</u>, 457 (1984).
- K. Murase, K. Yakushiji and T. Fukunaga, J. Non Cryst. Solids <u>59-60</u>, 855 (1983). Also see S. Sugai Phys. Rev. B<u>35</u>, 1345 (1987).

- 20. W.J. Bresser, P. Boolchand, P. Suranyi and J.P. deNeufville, Phys. Rev. Lett. 46, 1689 (1981).
- 21. M. Stevens, P. Boolchand and J.G. Hernandez, Phys. Rev. B31, 981 (1985).